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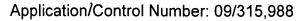
UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS Washington, D.C. 20231 www.uspto.gov

APPLICATION NO.	F	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/315,988		05/21/1999	HAJIME KAWANO	29273/502	7205
23838	7590	05/22/2002			
KENYON			EXAMINER		
1500 K STREET, N.W., SUITE 700 WASHINGTON, DC 20005				FERNANDEZ	, KALIMAH
				ART UNIT	PAPER NUMBER
				2881	
			DATE MAILED: 05/22/2002		

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	pplicant(s)
Office Action Summary	09/315,988	KAWANO ET AL.
Office Action Summary	Examiner	Art Unit
The MAILING DATE of this communication	Kalimah Fernandez	2881
The MAILING DATE of this communication Period for Reply	n appears on the cover sheet	with the correspondence address
A SHORTENED STATUTORY PERIOD FOR RITHE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CI after SIX (6) MONTHS from the mailing date of this communication. If the period for reply specified above is less than thirty (30) days, If NO period for reply is specified above, the maximum statutory provided in the second second second for reply within the set or extended period for reply will, by second secon	ON. FR 1.136(a). In no event, however, may on. a reply within the statutory minimum of the period will apply and will expire SIX (6) Minimum, and the period will apply and will expire SIX (6) Minimum to become	a reply be timely filed nirty (30) days will be considered timely. DNTHS from the mailing date of this communication. ABANDONED (35 U.S.C. § 133)
1) Responsive to communication(s) filed on	<u>2-14-02</u> .	
2a)☐ This action is FINAL . 2b)⊠	This action is non-final.	
3) Since this application is in condition for a closed in accordance with the practice ur Disposition of Claims		
4)⊠ Claim(s) <u>1-10</u> is/are pending in the applic	ation.	
4a) Of the above claim(s) is/are with	hdrawn from consideration.	
5) Claim(s) is/are allowed.		
6)⊠ Claim(s) <u>1-10</u> is/are rejected.		
7) Claim(s) is/are objected to.		
8) Claim(s) are subject to restriction a	nd/or election requirement.	
Application Papers		
9) The specification is objected to by the Exam	miner.	
10) The drawing(s) filed on is/are: a)	accepted or b) objected to by	the Examiner.
Applicant may not request that any objection	• , ,	• • • • • • • • • • • • • • • • • • • •
11) The proposed drawing correction filed on _	is: a) □ approved b) □	disapproved by the Examiner.
If approved, corrected drawings are required	• •	
12)☐ The oath or declaration is objected to by th	e Examiner.	
Priority under 35 U.S.C. §§ 119 and 120		•
13) Acknowledgment is made of a claim for fo	reign priority under 35 U.S.C	s. § 119(a)-(d) or (f).
a) ☐ All b) ☐ Some * c) ☐ None of:		
Certified copies of the priority docur	ments have been received.	
2. Certified copies of the priority docur	ments have been received in	Application No
3. Copies of the certified copies of the application from the Internationation of See the attached detailed Office action for a	al Bureau (PCT Rule 17.2(a)).
14) ☐ Acknowledgment is made of a claim for dor	mestic priority under 35 U.S.0	C. § 119(e) (to a provisional application).
a) The translation of the foreign languag 15) Acknowledgment is made of a claim for do		
Attachment(s)		
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-94) 3) Information Disclosure Statement(s) (PTO-1449) Paper N	8) 5) Notice	w Summary (PTO-413) Paper No(s) of Informal Patent Application (PTO-152)
U.S. Patent and Trademark Office PTO-326 (Rev. 04-01) Off	ice Action Summary	Part of Paper No. 11





Art Unit: 2881

DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 1-3 are rejected under 35 U.S.C. 102(b) as being anticipated by JP Doucment 7-201720 issued to Tamura.
- 3. Tamura discloses an electron beam lithography system (pg.14, parag. 22).

 Tamura discloses the generation of an exposure map (pg.2, summary of the invention; pg. 14, parag. 21).
- 4. Tamura discloses said exposure map based on coordinates/positional relations (see pg.12, parag. 17-18).
- 5. Tamura discloses a proximity effect correction means (see pg.13, para. 20).
- Tamura discloses a judging means for determining any overlap/straddling (pg.
 para. 18).
- 7. As per claim 2, see figs. 6-7; pg. 17, parag. 29.
- 8. As per claim 3, Tamura discloses adding the area density of an overlap area to the pattern in question (pg. 18, parag.32-33).



Application/Control Number: 09/315,988

Art Unit: 2881

Claim Rejections - 35 USC § 103

- 9. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 10. Claims 4-10 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tamura and in view of US Pat No 4,692,579 issued to Saitou et al.
- 11. In regards to claims 4 and 10, Tamura teaches the claimed invention except for NxM memories.
- 12. However, Saitou teaches a conventional exposure map having N parts in the direction of width and M in the direction of height (col.4, 18-27).
- 13. It would have been obvious to a person having ordinary skill in the art to incorporate the teaching of Saitou into Tamura, since Saitou teaches improved time and accuracy (col.2, lines 30-40).
- 14. As per claims 5 and 7, Tamura teaches a bit map generated by a memory means (pg.14, para. 21). Tamura teaches a read-out means for constructing a new pattern density map from the memory data addressed to two different memories (pg 11-12, para. 15-16).
- 15. As per claim 6, Tamura discloses adding the area density of an overlap area to the pattern in question (pg. 18, parag.32-33).



Application/Control Number: 09/315,988

Art Unit: 2881

- 16. Claims 8-9 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tamura and Saitou as applied to claim 4 above, and further in view of US Pat 3,921,135 issued to Komaru et al.
- 17. The obvious combination of Tamura and Saitou teaches the claimed invention except for selecting means.
- 18. However, Komaru teaches a memory system for dividing a larger area using NxM (see col.3, lines 19-45). Komaru, also, teaches the conventional selection of memories for retrieval of stored data (col.4, line 59-col.5, line 4).
- 19. It would have been obvious to an ordinary skilled artisan to incorporate the teachings of Komaru into Tamura, since Komaru teaches an efficient manner to decrease memory capacity without lowering quality (col.1, lines 30-34).

Response to Arguments

20. Applicant's arguments with respect to claims 1-10 have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

- 21. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. JP Doucment 60198432 issued to Konishi.
- 22. Konishi discloses an address generating means to select the address of memory (see abstract).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kalimah Fernandez whose telephone number is 703-



Application/Control Number: 09/315,988

Art Unit: 2881

305-6310. The examiner can normally be reached on Mon-Fri between 7:00am-3:30pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Lee can be reached on 703-308-4116. The fax phone numbers for the organization where this application or proceeding is assigned are 703-308-7722 for regular communications and 703-872-9319 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

kf May 14, 2002

SUPERVISORY PATENT EXAMINER
TECHNOLOGY CENTER 2800